WELLBORE CLEANUP & DISPLACEMENT PRODUCT

TETRACLEAN 106 SURFACTANT ACTIVATOR

Displacement System

OVERVIEW

TETRAClean 106 displacement system is an environmentally-friendly, proprietary blend of inorganic salts designed to activate the TETRAClean 105 surfactant in the TETRAClean displacement system.

APPLICATIONS

TETRAClean 106 displacement system is added at the recommended treatment rate with gentle agitation to promote uniform mixing. TETRAClean 106 displacement system is used at 2 - 6% vol/vol as an activator to TETRAClean 105 surfactant.

FEATURES AND BENEFITS

- Combines with TETRAClean 105 displacement system to provide synergistic cleaning during wellbore displacement of water-, oil- and synthetic-based muds.
- ▶ Compatible with water, sodium, brines, and lightweight calcium brines.
- Has been given an Offshore Chemical Notification Scheme (OCNS) category E (PLONOR listing).

RECOMMENDED TREATMENT

Treatment rate for TETRAClean 106 displacement system used in wellbore cleanup can range from 2% to 6% vol/vol in combination with TETRAClean 105 displacement system in formulation of a TETRAClean displacement system.

SAFETY AND HANDLING

Refer to the Safety Data Sheet for specific details.

PHYSICAL PROPERTIES

Appearance Colorless liquid

Specific Gravity 1.09 - 1.10 @ 68°C (20°C)

рН 8.5 - 9.1

Flash Point Not applicable

Water Solubility Soluble

PACKAGING INFORMATION

- 200 liter drum
- 1000 liter IBC



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